

Advance Product Change Notification

Issue Date: 30-Oct-2015

Here's your personalized quality information concerning products Digi-Key purchased from NXP. For detailed information we invite you to view this notification online

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Management Summary

Chand	ne to	state	of the	he a	rt litho	ograp	hv t	ools	and	introd	dution	of	advanced	die	protection	techno	loav

Change Categor	' V		p
[X] Wafer Fab process		cess [] Product Marking	[] Design
[] Wafer Fab materials	[] Assembly Materials	[] Electrical spec./Test coverage	[] Mechanical Specification
[] Wafer Fab locat	ion [] Assembly Loc	ation[] Test Location	[] Packing/Shipping/Labeling
Change of A wafer coating		raphy tool and impleme	ntation of additional

Details of this Planned Change

1. Photolithography tool will be changed from PE mask aligner tool towards PAS stepper tool.

This requires adaption of wafer layout and new mask sets.

Die design will not be changed.

Individual information about die coordinates in the die layout will be removed because of stepper technology.

Stepper lithography is the more advanced standard technology in wafer fab processing.

2. Additional wafer coat layer as surface protection

This requires an additional mask step.

Wafer coat protection is standard process in IC wafer fab manufacturing.

Why do we Plan this Change

1. Discontinuation of old photolithography technology.

Stepper litography delivers improved accuracy.

2. Robustness improvement against potential surface damages and contamination.

Reduction of mechanical package stress on the die.

Identification of Affected Products

Identification by lot-ID and datecodes on lables on packages

Product Availability

Sample Information

Samples are available from 01-Feb-2016

Production

Planned first shipment 01-Sep-2016

Impact

no impact to the product's functionality anticipated.

Disposition of Old Products

Existing inventory will be shipped until depleted

Additional information

Affected products and sales history information: see attached file

Self qualification: view online

Timing and Logistics

The Self Qualification Report will be ready on 30-Apr-2016.

The Final PCN is planned to be issued on: 30-Apr-2016.

Your acknowledgement of this change, conform JEDEC JESD46 D, is expected till 29-Nov-2015.

Contact and Support

For all inquiries regarding the ePCN tool application or access issues, please contact NXP "Global Quality Support Team".

For all Quality Notification content inquiries, please contact your local NXP Sales Support team.

For specific questions on this notice or the products affected please contact our specialist directly:

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Position Customer Quality Manager e-mail address ingobert.gorlt@nxp.com

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reach the highest possible Quality Standards.

Customer Focus, Passion to Win.

NXP Quality Management Team.

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